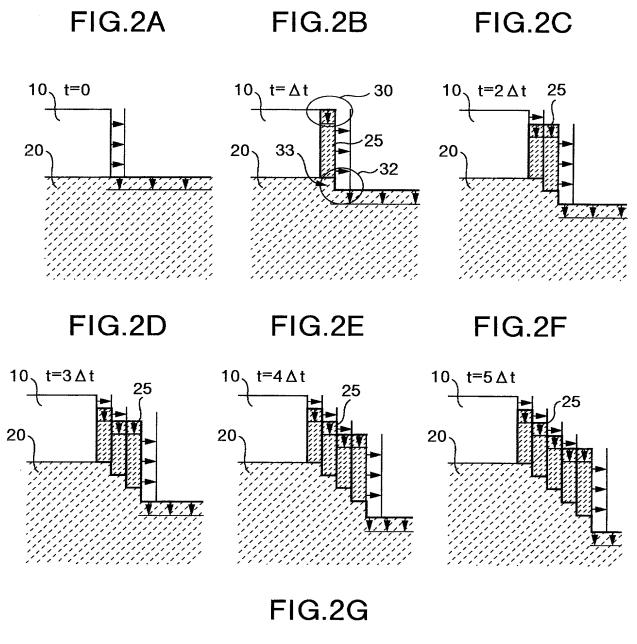
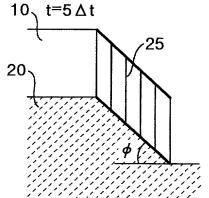
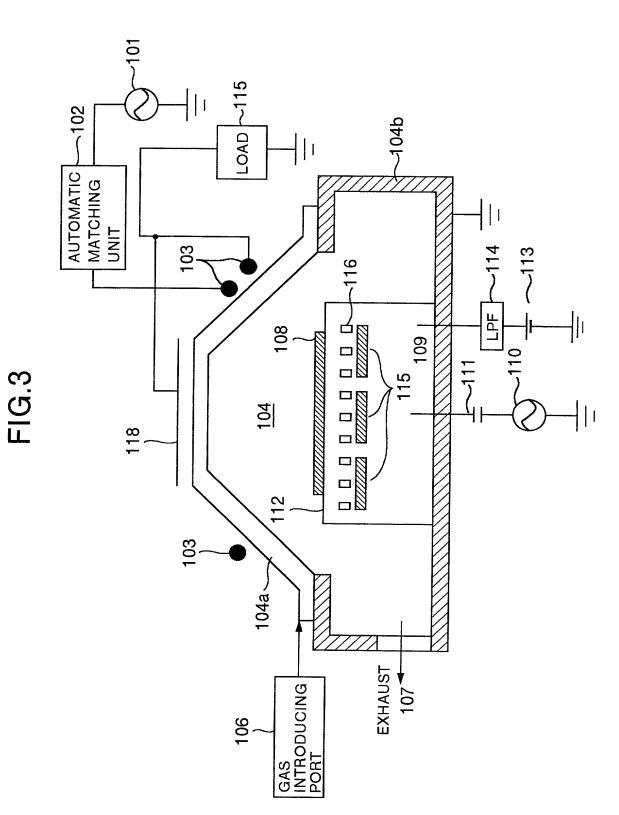
FIG.1F

FIG.1C FIG.1B FÍG.1A 10 10. 10 21 20 20 20 21 21 33 ////32

FIG.1E FIG.1D 10、 10. 10. 25 25 20 20 20 21







() L

FIG.4A
BEFORE ETCHING

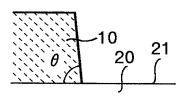


FIG.4B

**AFTER ETCHING** 

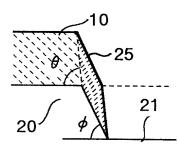


FIG.4C

AFTER REMOVAL OF DEPOSITION MATERIAL

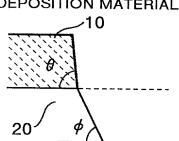


FIG.4D

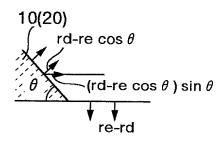


FIG.5A

PARALLEL WITH SIDE WALL OF MASK

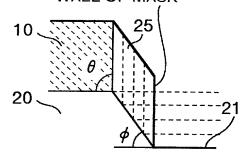


FIG.5C

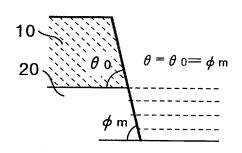


FIG.5B

DEPOSITION

MATERIAL IS EXPOSED

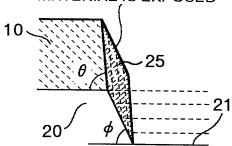


FIG.5D

MASK OR UNDERLYING MATERIAL IS EXPOSED

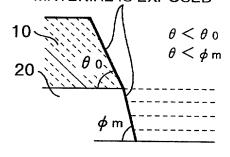
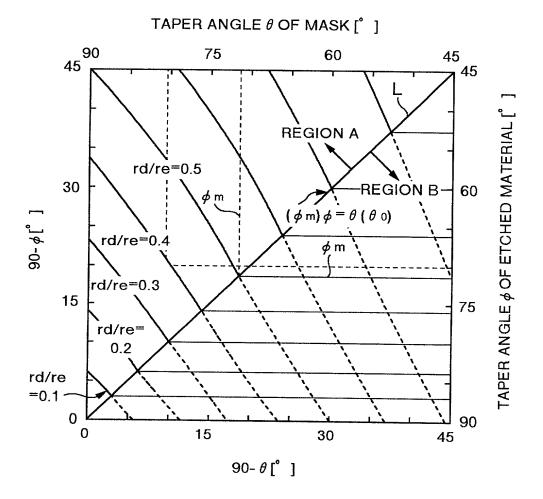
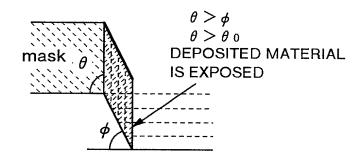


FIG.6



## FIG.7A

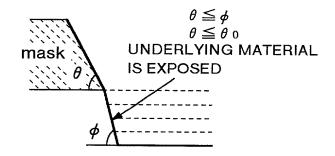
### **REGION A**



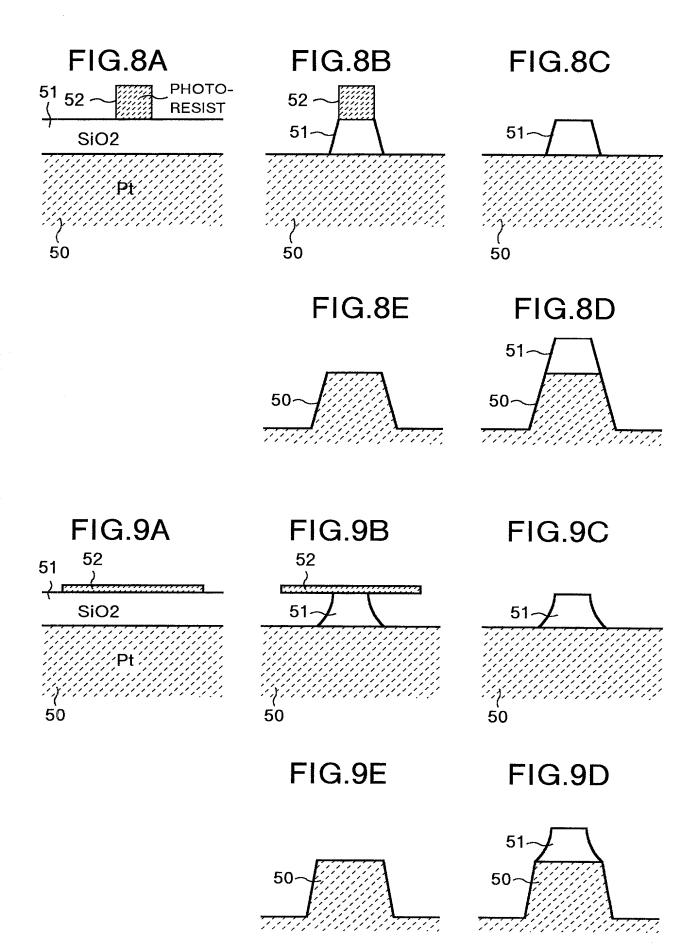
DEPOSITION MATERIAL ATTACHES TO MASK, TAPER ANGLE  $\phi$  OF ETCHED MATERIAL IS DETERMINED BY TAPER ANGLE  $\theta$  OF MASK

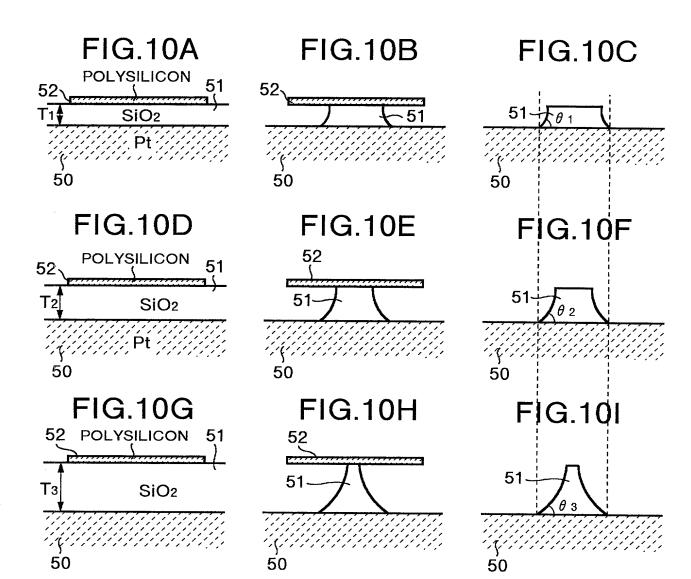
# FIG.7B

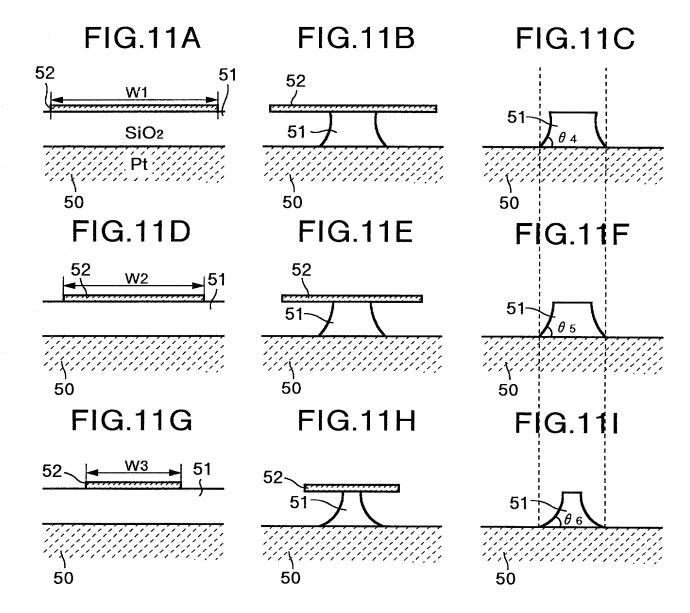
### **REGION B**



NO DEPOSITION MATERIAL ATTACHES TO MASK, TAPER ANGLE  $\phi$  OF ETCHED MATERIAL IS INDEPENDENT OF TAPER ANGLE  $\theta$  OF MASK



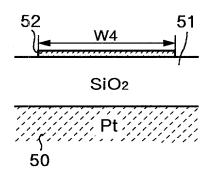


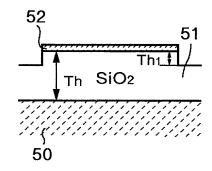




# FIG.12B

FIG.12C





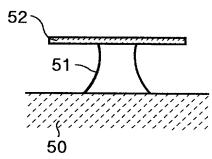


FIG.12D

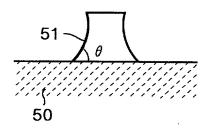
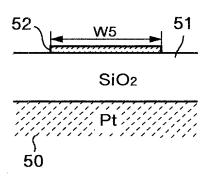
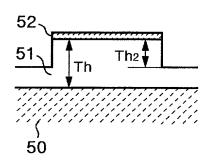


FIG.13A

FIG.13B

FIG.13C





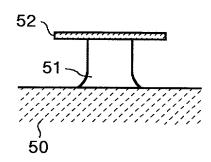


FIG.13D

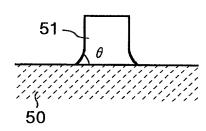
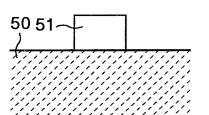
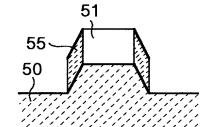


FIG.14A

FIG.14B

FIG.14C





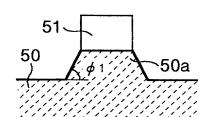
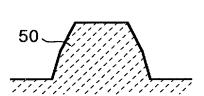
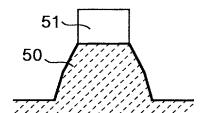


FIG.14F

FIG.14E

FIG.14D





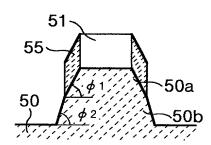


FIG.15A

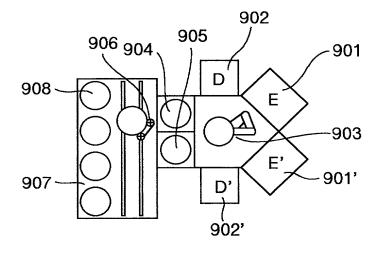


FIG.15B

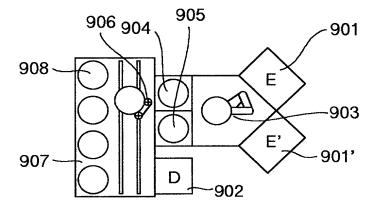
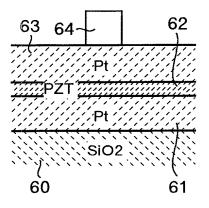
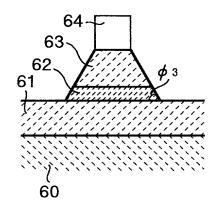


FIG.16A

FIG.16B

FIG.16C





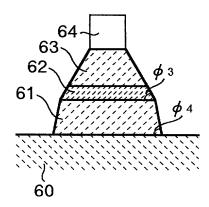
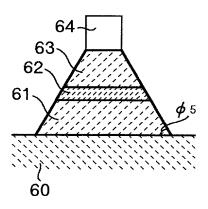


FIG.16D



# FIG.17A

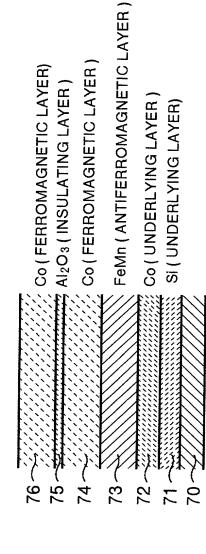


FIG.17B

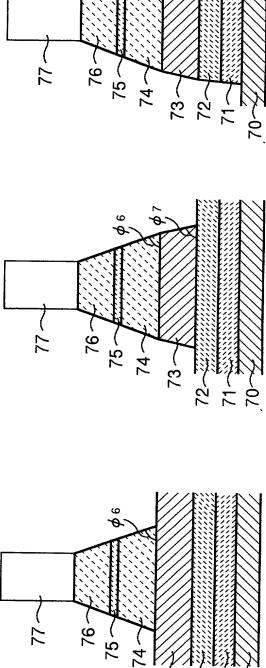


FIG.17D

FIG.17C

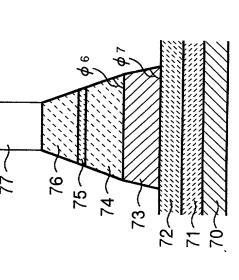


FIG.18

